

INFORMATION DISCLOSURE STATEMENT BY APPLICANTS PTO FORM 1449	Atty. Docket No. 10191/3165	Serial No. 10/614,540
	Applicant(s) SIEGLE et al.	
	Filing Date July 7, 2003	Group 2561

U. S. PATENT DOCUMENTS

EXAMINER'S INITIALS	PATENT NUMBER	PATENT DATE	NAME	CLASS	SUBCLASS	FILING DATE

FOREIGN PATENT DOCUMENTS

EXAMINER'S INITIALS	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB-CLASS	TRANSLATION	
						YES	NO
PD	1007 46 58	March 17, 1998	Japan			* abstract	

OTHER DOCUMENTS

EXAMINER'S INITIALS	AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.	
PD	Lee K et al., "Enhanced tunneling magnetoresistance and thermal stability of magnetic tunnel junction by rapid thermal anneal", JOURNAL OF MAGNETISM AND MAGNETIC MATERIALS, ELSEVIER, AMSTRDAM, NL., Bd. 239, Nr. 1-3, 02/2002, S. 120-122, XP-004351733.	
PD	Wu et al., "Thermal annealin study of spin valves", JOURNAL OF APPLIED PHYSICS, Bd. 89, Nr. 01-06-11, S.7616-7618, XP-001072884.	

EXAMINER	PHUC T. DANG	DATE CONSIDERED	6/15/05
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PD	2001/0055775	Dec. 27, 2001	Schultz et al.	—	—	
PD	4,670,088	June 2, 1987	Tsaur et al.	—	—	

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						YES	NO
PD	WO 00/79298	Dec. 28, 2000	PCT	—	—	NA	

OTHER DOCUMENTS

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